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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Noriyoshi SATO et al.

Group Art Unit: 2812

Application No.: 10/539,569

Docket No.: 124305

Filed: August 18, 2005

For: PLASMA GENERATOR, OZONE GENERATOR, SUBSTRATE PROCESSING
APPARATUS AND METHOD OF MANUFACTURING SEMICONDUCTOR
DEVICE

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

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JAO:RBI/rec

Date: April 19, 2007

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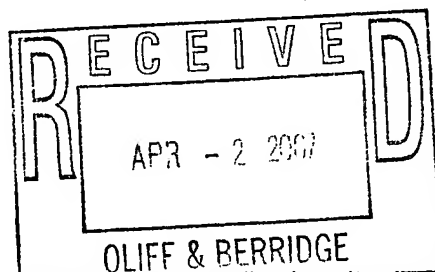
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APPL NO.	FILING OR 371(c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	TOT CLMS	IND CLMS
10/539,569	08/18/2005	2812	2080	124305	21	8

CONFIRMATION NO. 4496

25944
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P.O. BOX 19928
ALEXANDRIA, VA 22320



CORRECTED FILING RECEIPT



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Date Mailed: 03/23/2007

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Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/16887 12/26/2003

Foreign Applications

JAPAN 2002-379963 12/27/2002

If Required, Foreign Filing License Granted: 05/16/2006

The country code and number of your priority application, to be used for filing abroad under the Paris

Convention, is **US10/539,569**

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No

Title

Plasma generator, ozone generator, substrate processing apparatus and manufacturing method of semiconductor device

Preliminary Class

438

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